

(Abstract Domain : any one from 1-6)

Title (Times new roman, font size 14)

Presenting Author¹, Co-Authors^{2,*} (Times new roman, font size 12)

Department, Organisation, Address, City, Country (Italic, Times new roman, font size 11)

*Corresponding Author E-mail: (Times new roman, font size 10) (only one)

ABSTRACT (Times new roman, font size 11) (Max. 500 words with one figure/schematic)

You are invited to submit your abstract (maximum 500 words). Authors whose abstracts are selected will be invited for presenting the paper in the conference “3rd International Conference on Thin Films and Nanotechnology: Knowledge, Leadership and Commercialization 2025” at IIT Delhi. After presentation the authors will be asked to submit a full-length paper for further consideration after a blind peer review process. to submit a full paper for peer review.

The topic of the Conference abstract domain includes

1. Thin films/Nano-materials Growth, Novel techniques and concepts
2. Materials & coating for batteries, super-capacitors and fuel cells
3. Microelectronics and optoelectronics devices
4. Computational modelling & simulations
5. Perovskite, Silicon and CdTe thin films solar cells
6. Coating materials for wind and hydro turbine blades

This Abstract Template must be used for abstract submission.

Abstracts of a maximum of 500 words must be submitted online by September 30, 2025. Authors will be notified of abstract acceptance by October 15, 2025.

Keywords: Keyword1; Keyword2; Keyword3; Keyword4; (Maximum 4).